



POOR MAN'S INTRO TO BONDING

KiCon ASIA 2025



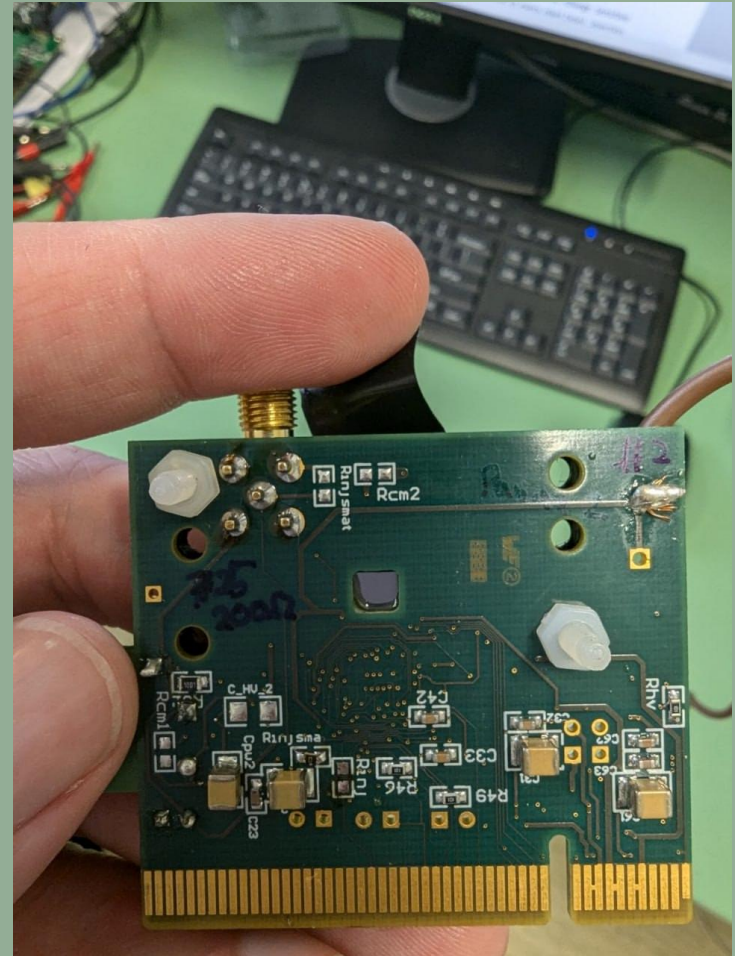
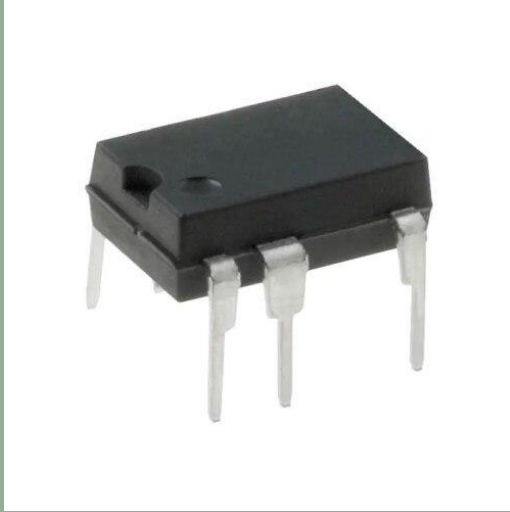
OPEN SKUNKFORCE E.V.

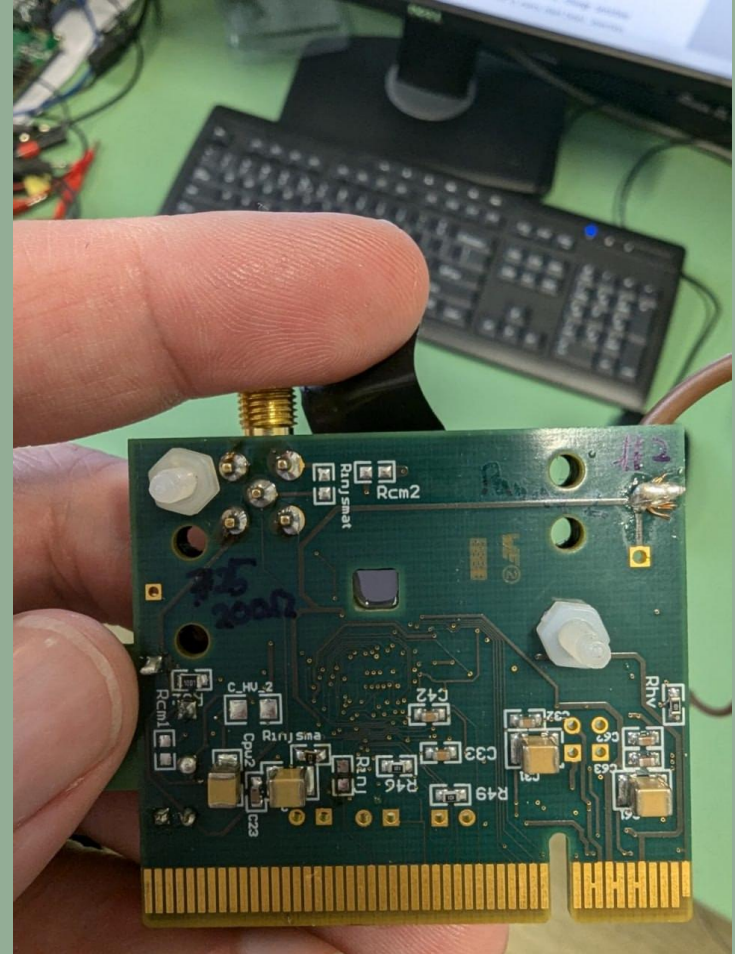
CONNECTING ENGINEERS AND
UNIVERSITIES

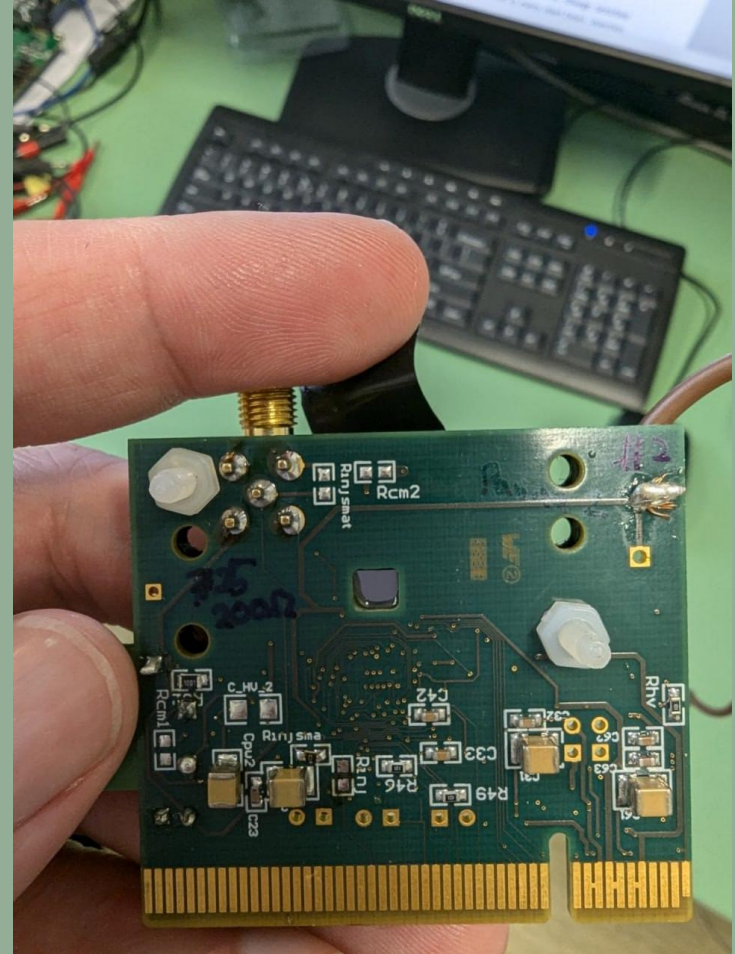
RUNNING CONFERENCES

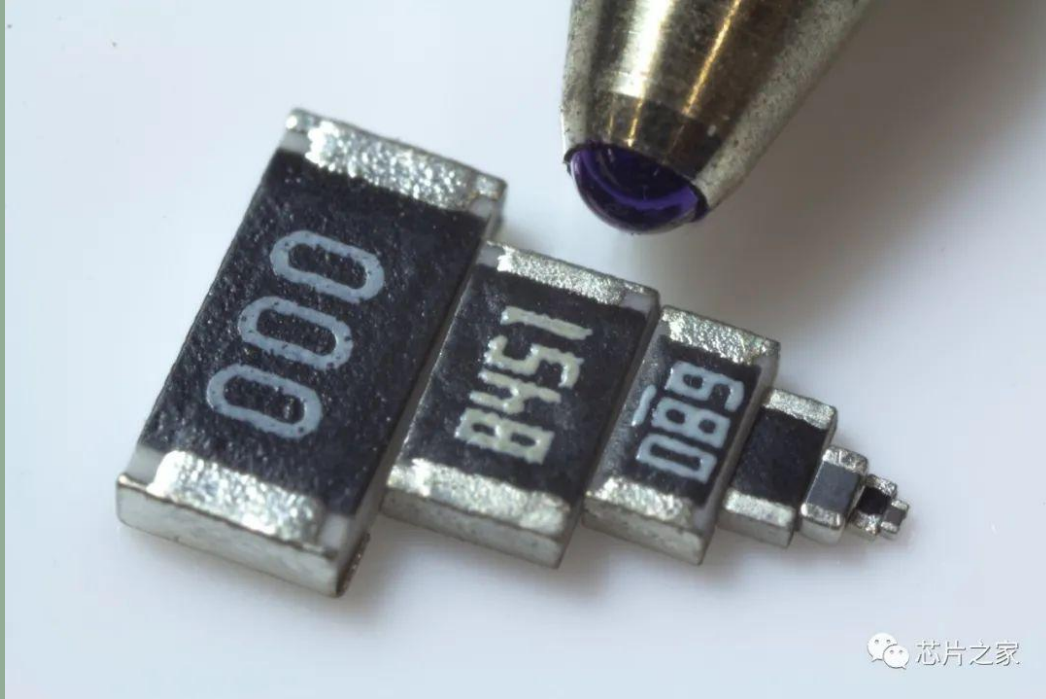
SINCE 2021

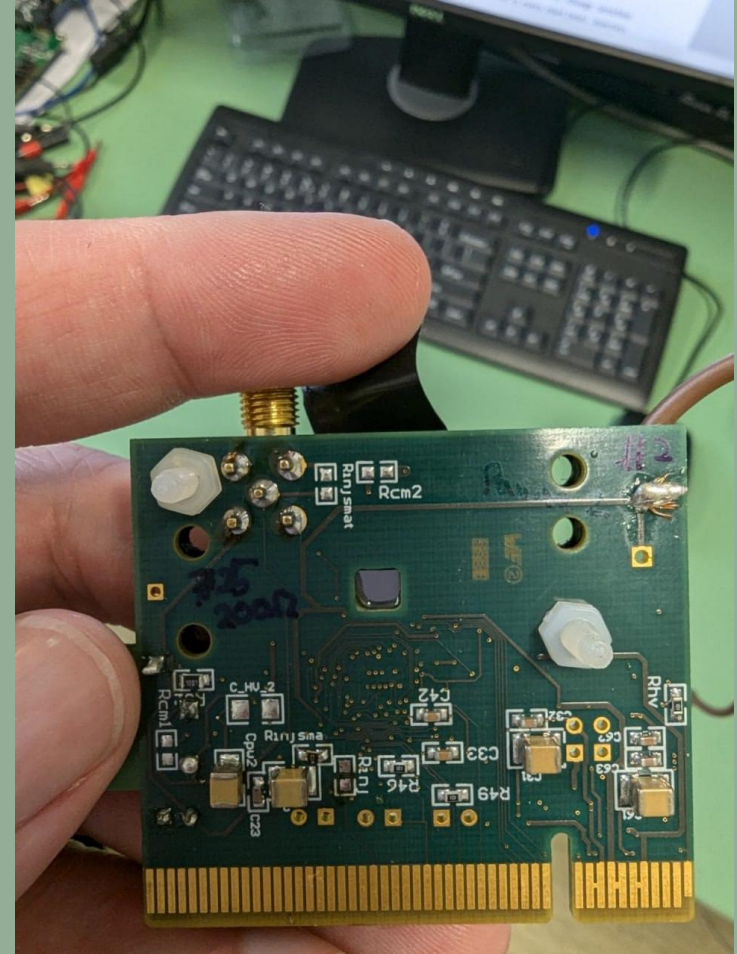
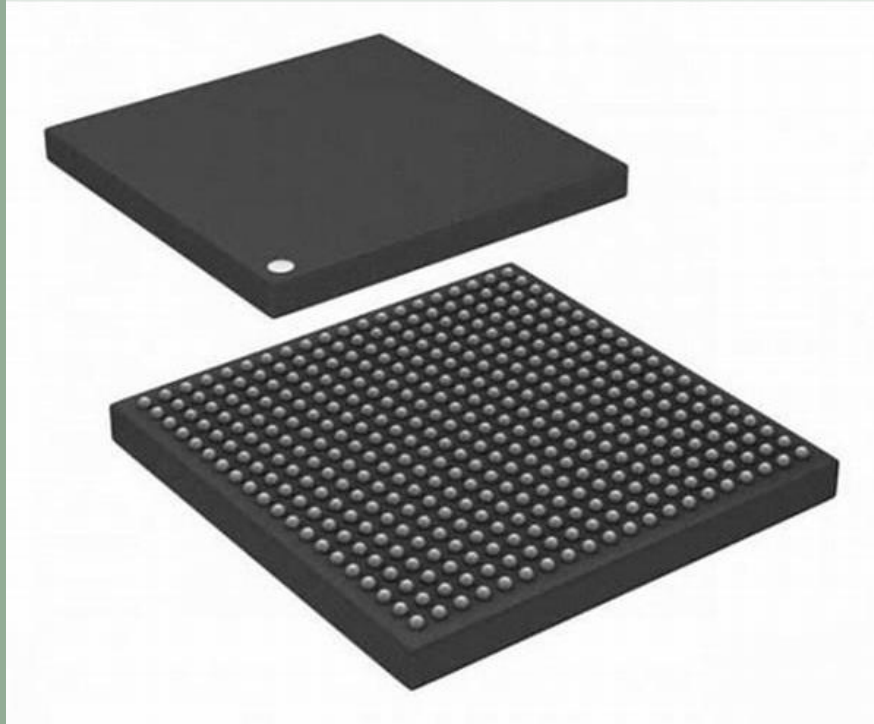


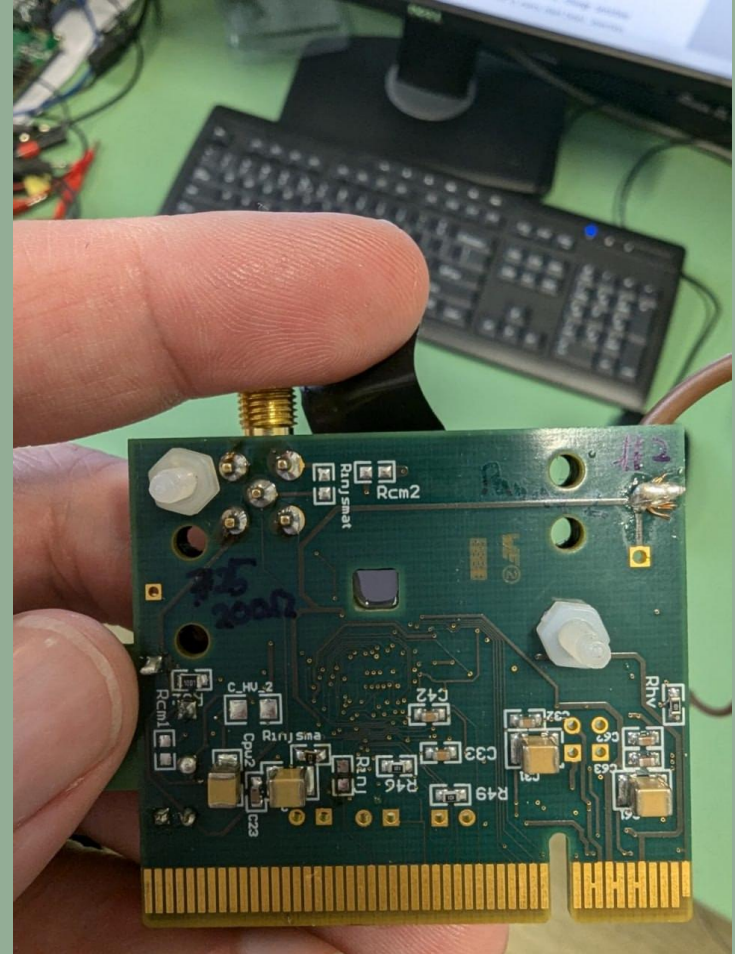
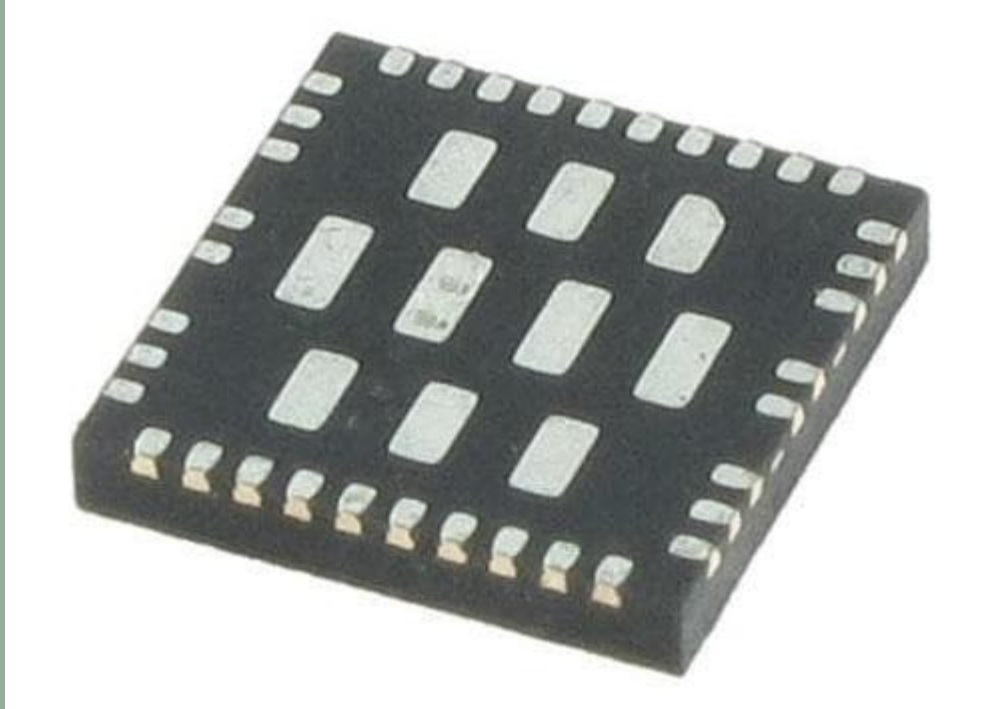


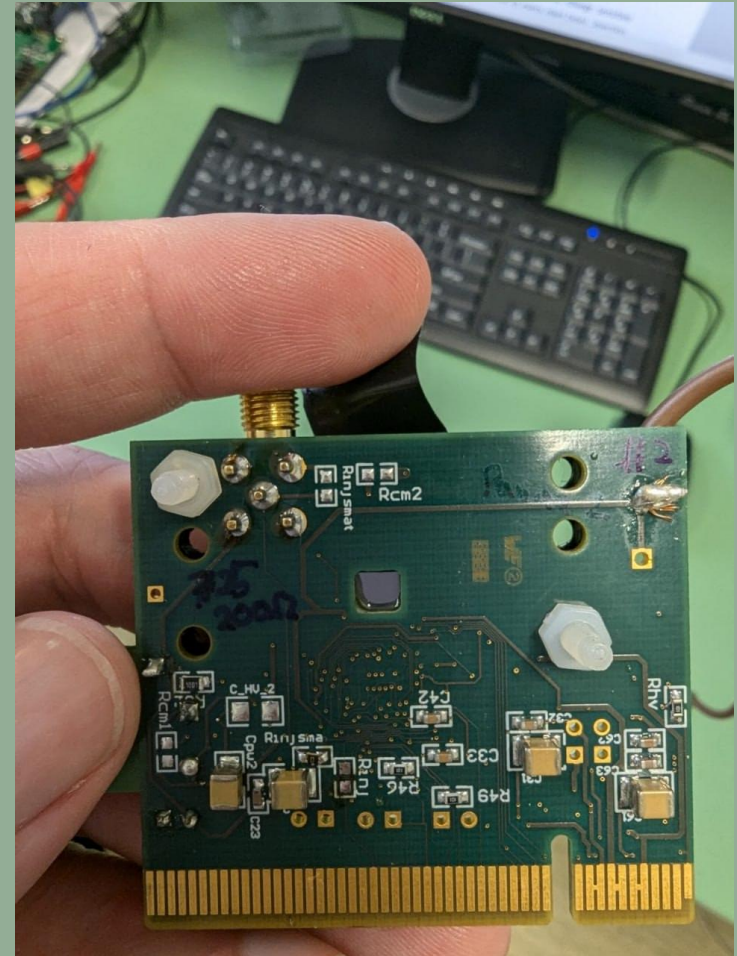
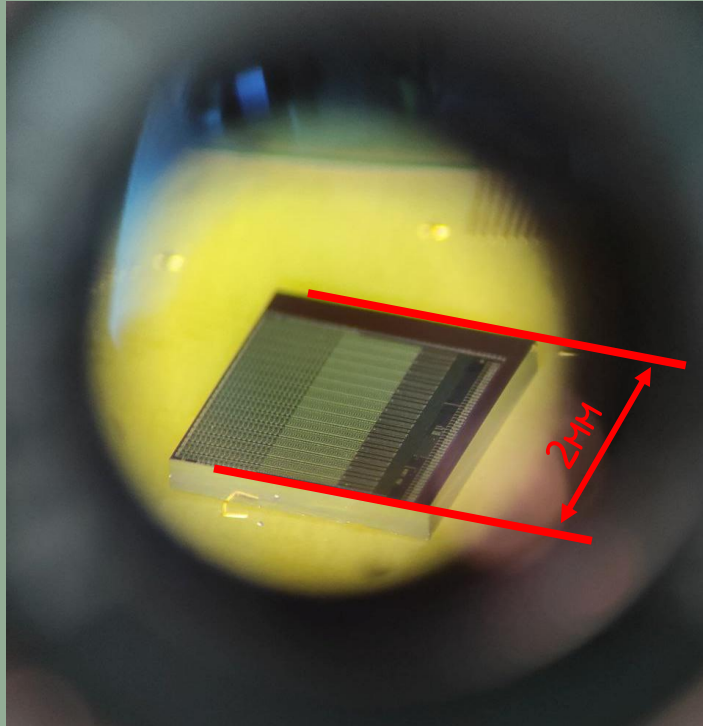


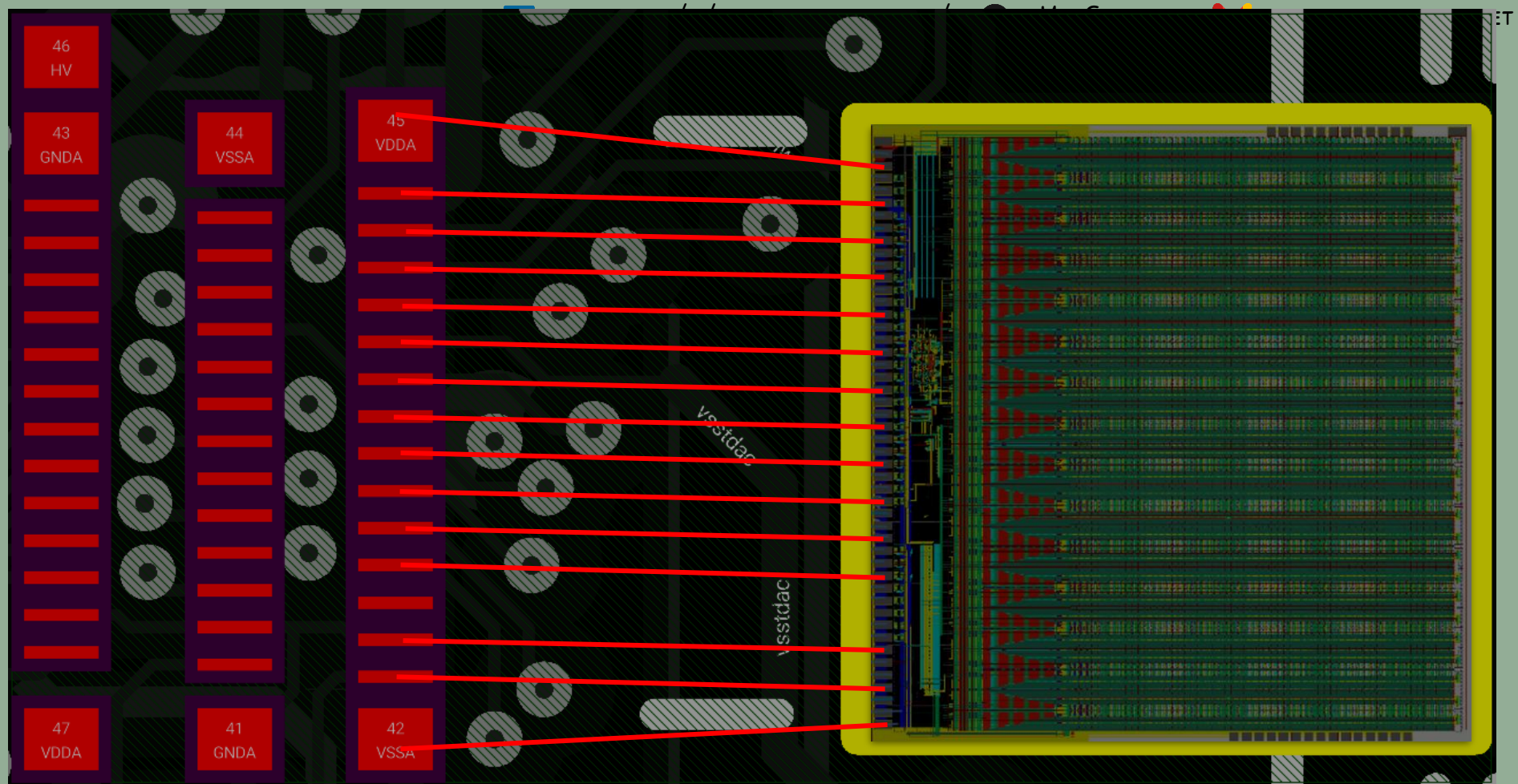


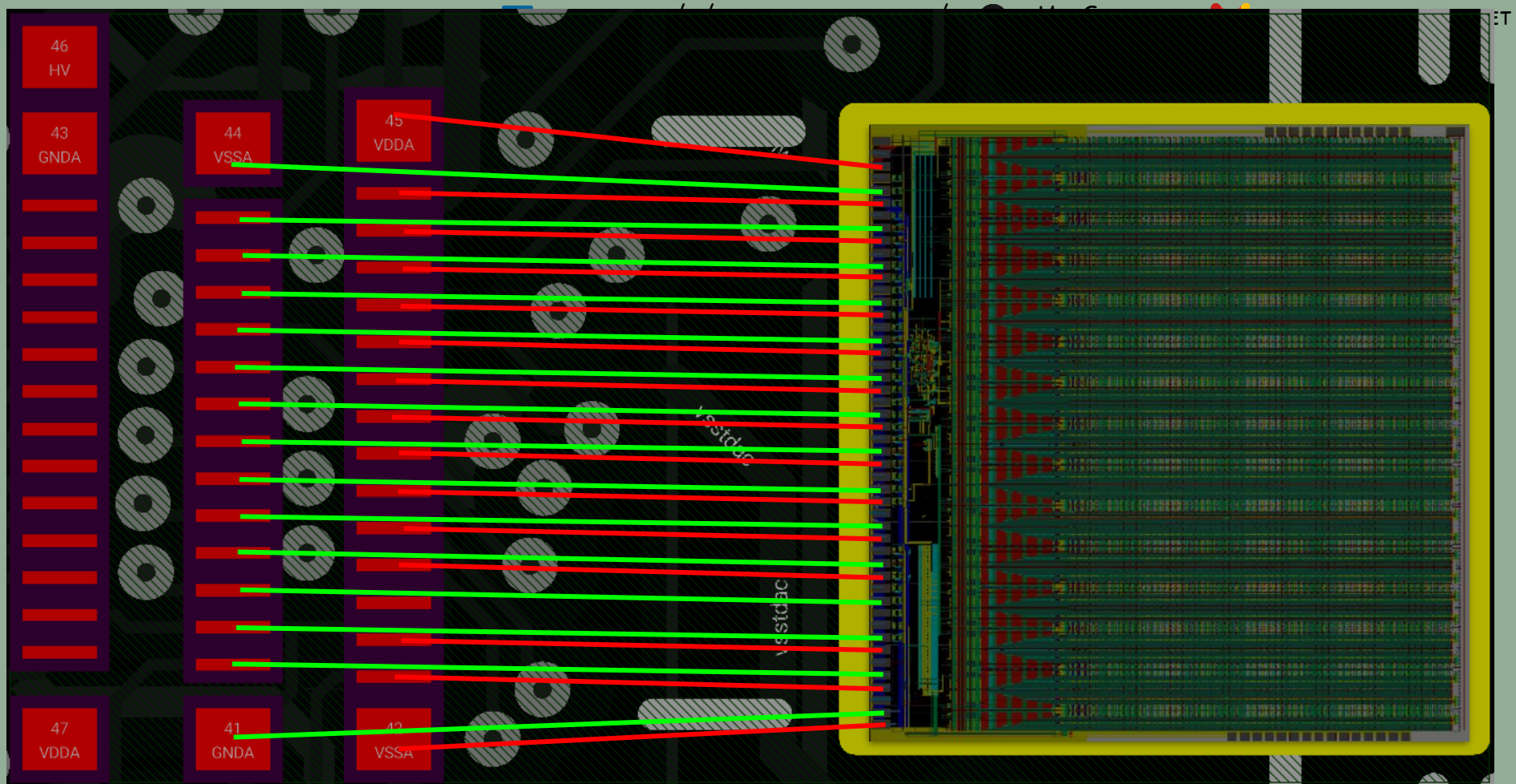


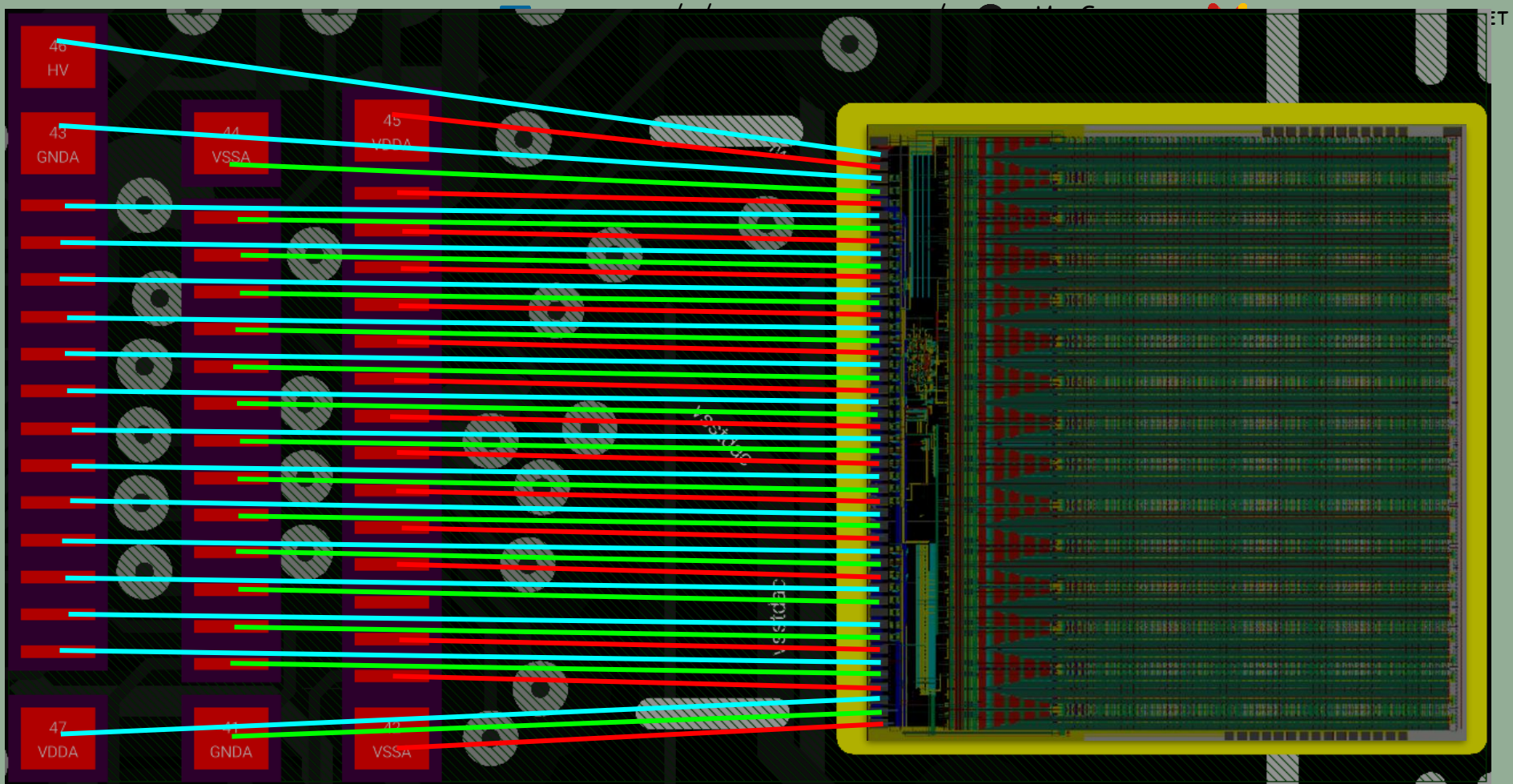


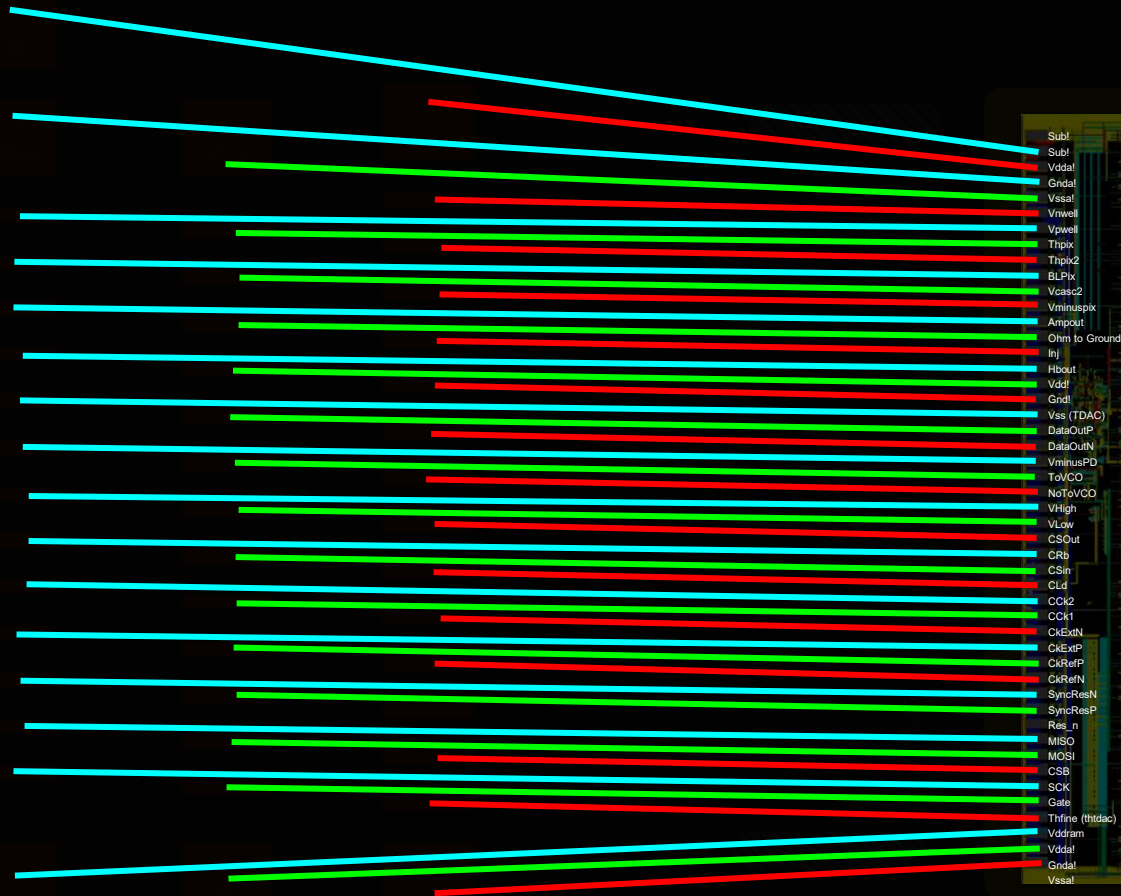












Subl	(pixels) -60V min
Subl	(chip ring) -60V min
Vddal	Analog power 1V8
Gndal	Analog Ground
Vssa	Analog power for the input PMOS of pxi-amp 1V2
Vnwell	pxl nwell bias 1V8 to 2V8
Vpwell	pxl pwell bias -1V to 0V
Thpix	Threshold for the main comparator BLPix + 50mV
Thpix2	Threshold for the slow comparator BLPix + 50mV
BLPix	Base line voltage of the pxi CR filter 1V in pxi
Vcas2	PMOS cascode voltage in the pxi amp 0V8
Vminuspix	Source voltage for the pxi line driver 0V5 - 1V5
Ampout	Source follower output - amplifier output, connect 1k
Ohm to Ground	
Inj	Analog input injection signal
Hbout	Source follower output - hit bus, connect 1kOhm to Gnd
Vddt	Digital power - 1V8
Gndt	Digital Ground
Vss (TDAC)	Current drain for regulated cascode receiver - 0V3
DataOutP	Digital out, LVDS, data out connect 100 Ohm pull up
DataOutN	Digital out, LVDS, data out connect 100 Ohm pull up
VminusPD	Ground for pull down transistor 0V
ToVCO	VCO bias, connect 1k and 1n in series
NoToVCO	VCO bias, connect 1k and 1n in series
VHigh	Power for PLL 1V8
VLow	Ground for PLL 0V
CSOut	Digital out, CMOS 1V8, shift register interface
CRb	Digital in, CMOS 1V8, shift register interface
CSin	Digital in, CMOS 1V8, shift register interface
CLd	Digital in, CMOS 1V8, shift register interface
CCK2	Digital in, CMOS 1V8, shift register interface
CCK1	Digital in, CMOS 1V8, shift register interface
CkExtN	Digital in, LCDS, external clk (no termination)
CkExtP	Digital in, LCDS, external clk (no termination)
CkRefN	Digital in, LCDS, reference clk for PLL (no termination)
CkRefP	Digital in, LCDS, reference clk for PLL (no termination)
SyncResN	Digital in, LCDS, sync reset (on chip termination)
SyncResP	Digital in, LCDS, sync reset (on chip termination)
Res_n	Digital in, CMOS 1V8, async reset active 0
MISO	Digital out, CMOS 1V8, SPI
MOSI	Digital in, CMOS 1V8, SPI
CSB	Digital in, CMOS 1V8, SPI
SCK	Digital in, CMOS 1V8, SPI
Gate	Gate voltage for NMOS comparator 2V1
Thfine (thtdac)	Threshold for TDC 1V4
Vddram	Vdd for RAM cells (1V5 - 1V8)
Vddal	Analog power 1V8
Gndal	Analog ground
Vssa	Analog power for input PMOS of pxi amp 1V2

Pad-Width =
80µm

Pad-Pitch =
100µm

WIRE BONDING – CONNECTING CHIPS TO ELECTRODES WITH FINE WIRES



ULTRASONIC WIRE-BONDING IS A SOLID-STATE WELDING PROCESS USED IN MICROELECTRONICS PACKAGING TO INTERCONNECT A FINE METALLIC WIRE (TYPICALLY GOLD, ALUMINUM, OR COPPER) TO A BOND PAD.

THE BONDING TOOL (CAPILLARY OR WEDGE) APPLIES A CONTROLLED FORCE AND TRANSMITS HIGH-FREQUENCY ULTRASONIC VIBRATIONS TO THE WIRE-SUBSTRATE INTERFACE.

THE ULTRASONIC ENERGY INDUCES LOCALIZED PLASTIC DEFORMATION AND SCRUBBING ACTION THAT BREAKS UP SURFACE OXIDES AND CONTAMINANTS, ENABLING DIRECT METAL-TO-METAL INTERDIFFUSION AND BOND FORMATION.

NON-THERMOACTIVATED ULTRASONIC WIRE-BONDING WORKS SOLELY THROUGH PRESSURE AND ULTRASONIC ENERGY. THIS METHOD IS PARTICULARLY SUITED FOR ALUMINUM WIRE BONDING TO ALUMINUM OR GOLD METALLIZATION IN TEMPERATURE-SENSITIVE DEVICES.



THE WIRE-BONDER

CNC-TOOL

UPWARDS OF \$150K

CLEANROOM OR CLEAN ROOM

MAIN INGREDIENTS

- VISIBILITY (CAMERA AND MICROSCOPE)
- CNC COMPUTER
- WIRE-FEED
- STAGE





THE WIRE-BONDER

CNC-TOOL

UPWARDS OF \$150K

CLEANROOM OR CLEAN ROOM

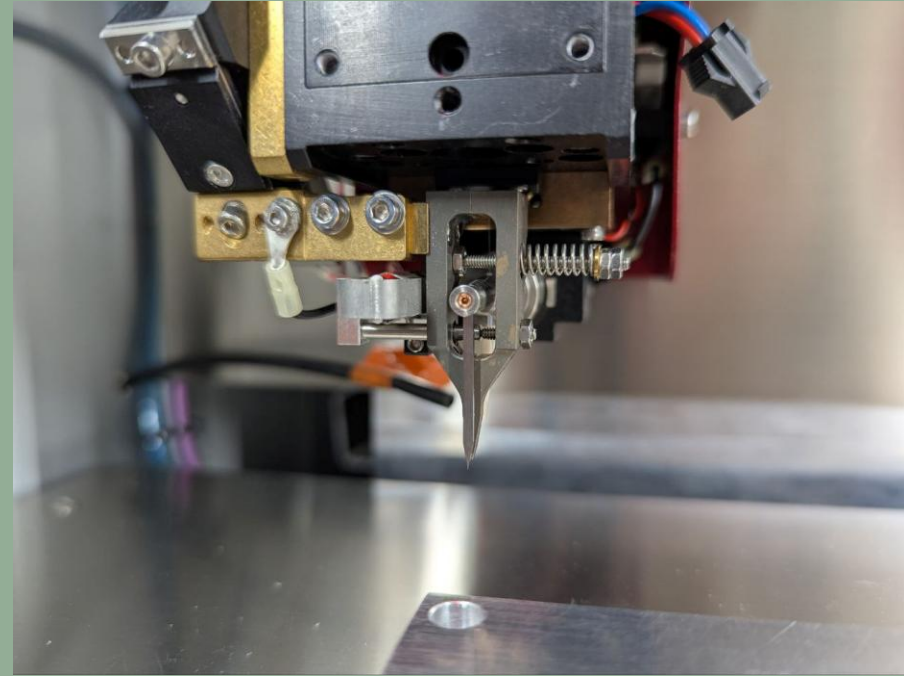
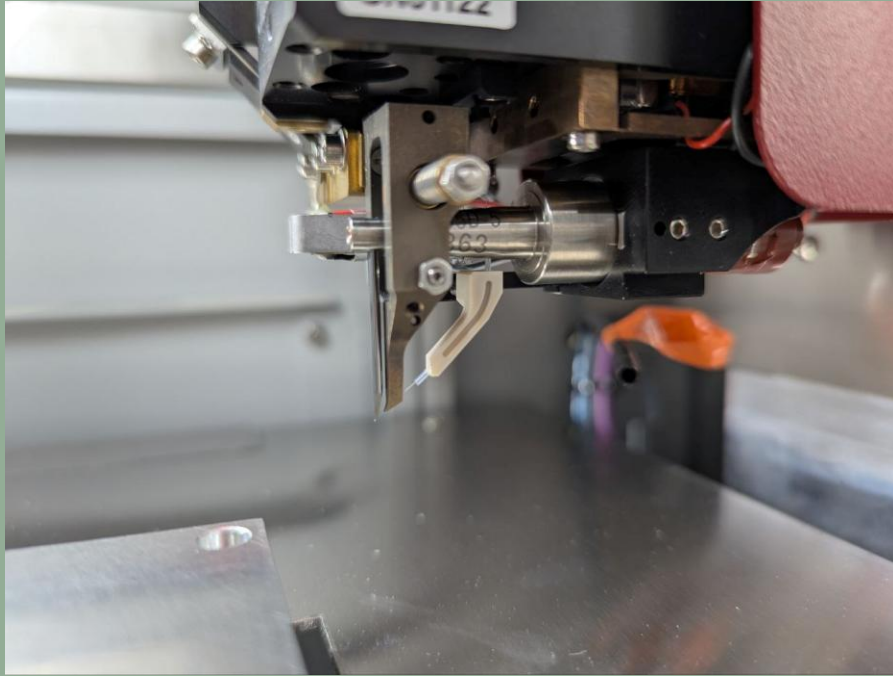
MAIN INGREDIENTS

- VISIBILITY (CAMERA AND MICROSCOPE)
- CNC COMPUTER
- WIRE-FEED
- STAGE
- BOND-TOOL / BOND-HEAD

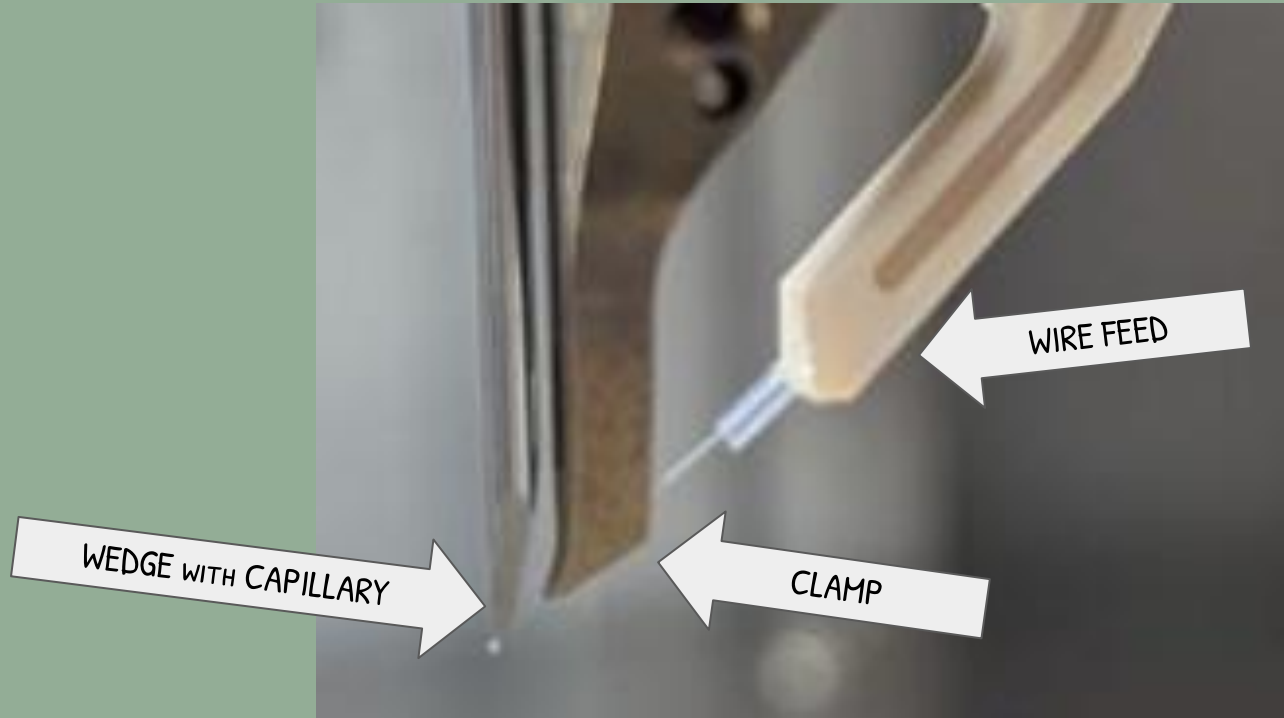




THE TOOL = WIRE-FEED + CLAMP + CAPILLARY + WEDGE



THE TOOL = WIRE-FEED + CLAMP + CAPILLARY + WEDGE





BETTER VIEW OF THE WEDGE

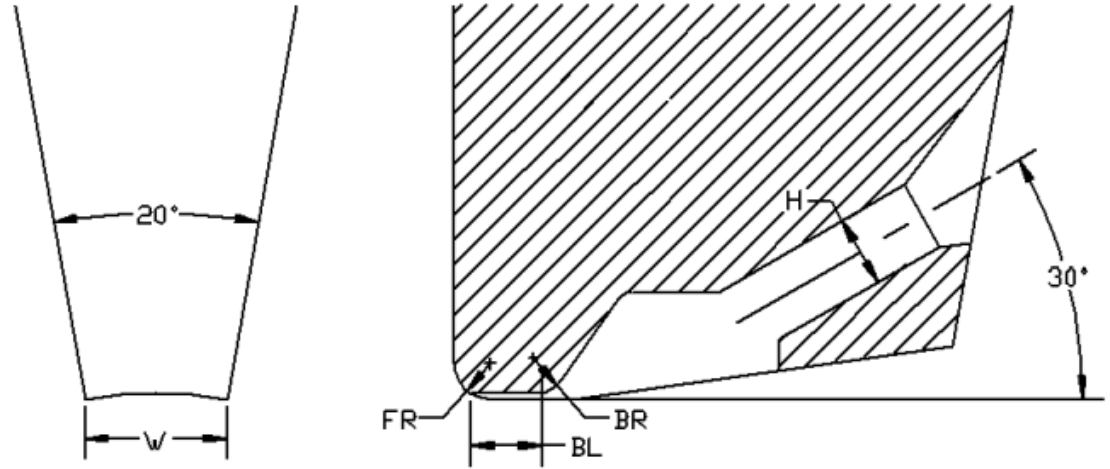


Figure 1: Schematic Diagram of the Wedge-shaped Capillary Cross-section.

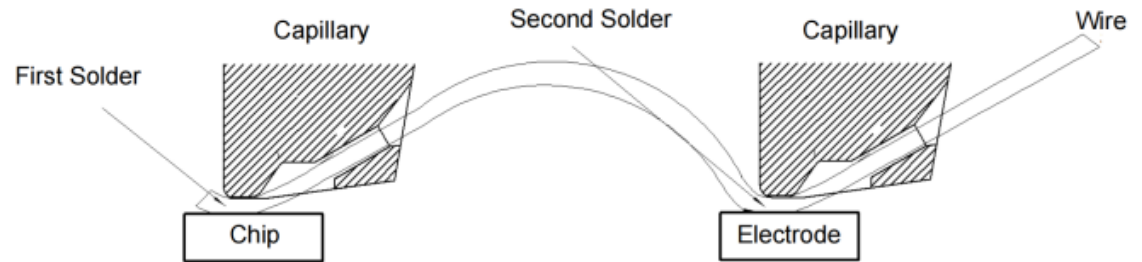


Figure 2: Schematic Diagram of Ultrasonic Wire Bonding.



INITIAL CONTACT

SCRUBBING

DEFORMATION

ATOMIC BONDING / INTERDIFFUSION

INTERMETALLIC COMPOUND

TEMPERING

FORM THE LOOP

SAME AGAIN

TEAR OFF

9 SIMPLE STEPS



INITIAL CONTACT

SCRUBBING

DEFORMATION

ATOMIC BONDING / INTERDIFFUSION

INTERMETALLIC COMPOUND

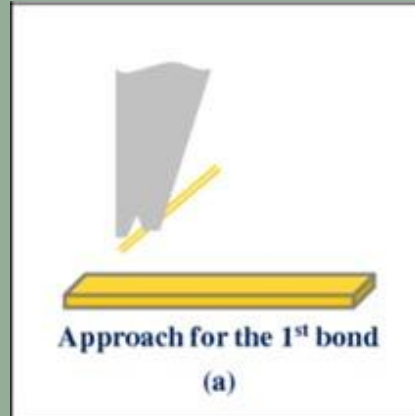
TEMPERING

FORM THE LOOP

SAME AGAIN

TEAR OFF

- SURFACE APPROACHES, PRESSURE BUILDS, ALIGNMENT BEGINS.
- ELECTRODES POSITION WIRE, SUBSTRATE REMAINS STABLE.
- MECHANICAL FORCE ESTABLISHES INITIAL INTIMATE CONTACT.
- ENERGY FOCUSES ACROSS MINUSCULE BONDING ZONE.
- WIRE CONFORMS, ADAPTING TO TARGET SURFACE.
- FOUNDATION FORMS FOR SUBSEQUENT METALLURGICAL PROCESSES.



INITIAL CONTACT

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INTERMETALLIC COMPOUND

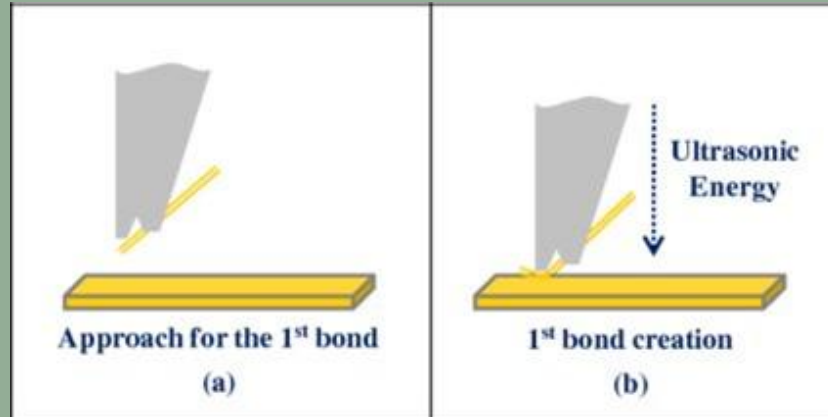
TEMPERING

FORM THE LOOP

SAME AGAIN

TEAR OFF

- ULTRASONIC VIBRATION INITIATES MICRO-SCALE SCRUBBING.
- RELATIVE MOTION REMOVES OXIDES AND CONTAMINANTS.
- SURFACE ASPERITIES BREAK, EXPOSING CLEAN METAL.
- FRICTIONAL ENERGY ENHANCES ATOMIC MOBILITY SIGNIFICANTLY.
- LOCALIZED MOTION DISRUPTS RESIDUAL INTERFACIAL BARRIERS.
- SCRUBBING ESTABLISHES PRISTINE CONTACT CONDITIONS RELIABLY.



INITIAL CONTACT

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INTERMETALLIC COMPOUND

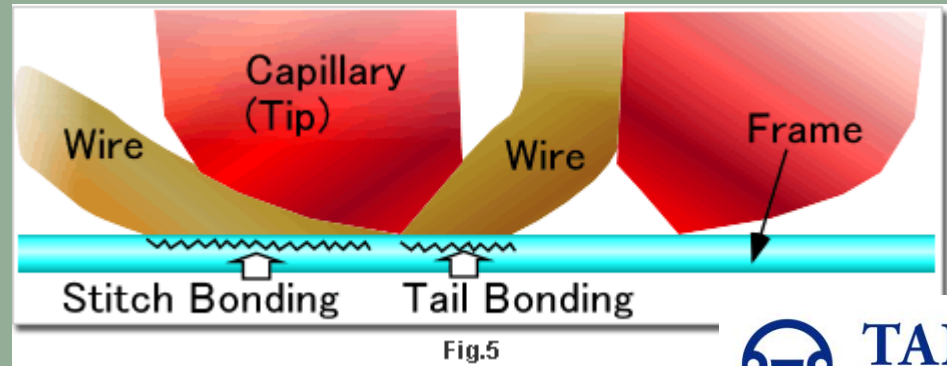
TEMPERING

FORM THE LOOP

SAME AGAIN

TEAR OFF

- APPLIED FORCE RESHAPES WIRE UNDER STRESS.
- PLASTIC FLOW ACCOMMODATES SURFACE IRREGULARITIES FULLY.
- WIRE FLATTENS, ENLARGING CONTACT AREA GRADUALLY.
- MECHANICAL SHAPING SUPPORTS STRONGER ATOMIC COUPLING.
- INTERFACES COMPRESS, REDUCING INTERFACIAL VOIDS.
- DEFORMATION PREPARES PATHWAY FOR INTERDIFFUSION PHENOMENA.



TANAKA
TANAKA PRECIOUS METALS

INITIAL CONTACT

SCRUBBING

DEFORMATION

ATOMIC BONDING / INTERDIFFUSION

INTERMETALLIC COMPOUND

TEMPERING

FORM THE LOOP

SAME AGAIN

TEAR OFF

- CLEAN METALLIC ATOMS ENCOUNTER NEIGHBORING ATOMS.
- DIFFUSION INITIATES ACROSS FRESHLY ACTIVATED INTERFACE.
- ATOMIC PROXIMITY ALLOWS ELECTRONIC ORBITAL OVERLAP.
- GRADUAL INTERDIFFUSION INTEGRATES WIRE AND PAD.
- METALLURGICAL COHESION STRENGTHENS MECHANICAL BOND INTEGRITY.
- ATOMIC ATTRACTION CONSOLIDATES IRREVERSIBLE METALLURGICAL JUNCTION.

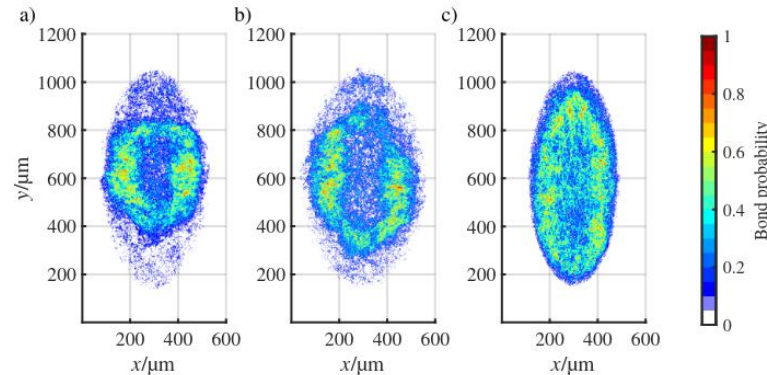


Figure 3.29: Results of image segmentation at 10,000 oscillation cycles of 15 pealed interface images for a) 37 kHz, b) 60 kHz and c) 100 kHz.

SCHEMEL, 2022

INITIAL CONTACT

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INTERMETALLIC COMPOUND

TEMPERING

FORM THE LOOP

SAME AGAIN

TEAR OFF

- DISTINCT PHASES FORM BETWEEN CONTACTING METALS.
- INTERMETALLIC COMPOUNDS NUCLEATE AT BONDING INTERFACE.
- GROWTH DEPENDS ON TEMPERATURE, TIME, CHEMISTRY.
- THESE COMPOUNDS STABILIZE INITIAL METALLURGICAL CONNECTION.
- EXCESSIVE GROWTH RISKS BRITTLE JOINT FORMATION.
- CONTROLLED KINETICS ENSURE RELIABLE INTERMETALLIC STRUCTURE.

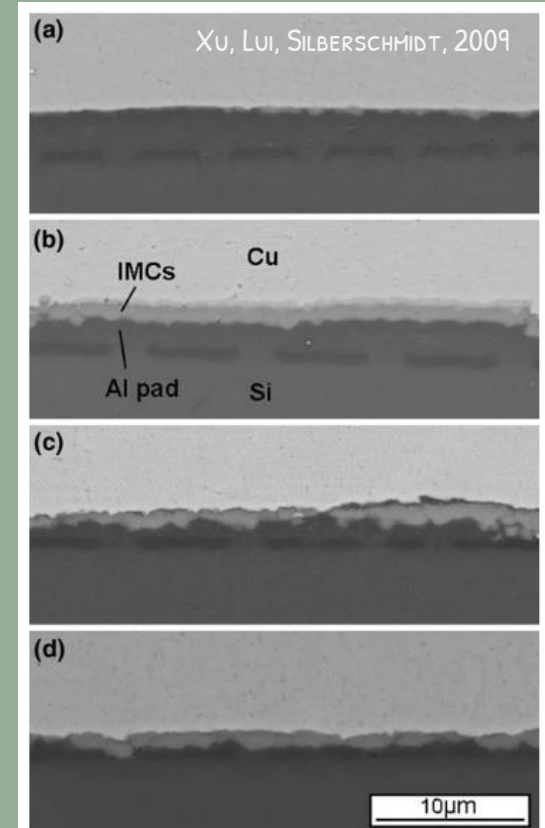


Fig. 6. Cross-sectional BSE SEM of copper ball/Al metallization interfaces after aging at 200°C for: (a) 1 day, very small IMCs formed; (b) 4 days, a layer of IMCs formed; (c) 64 days, thicker IMCs; and (d) 121 days, 1.5- μ m-thick IMCs formed.



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INTERMETALLIC COMPOUND

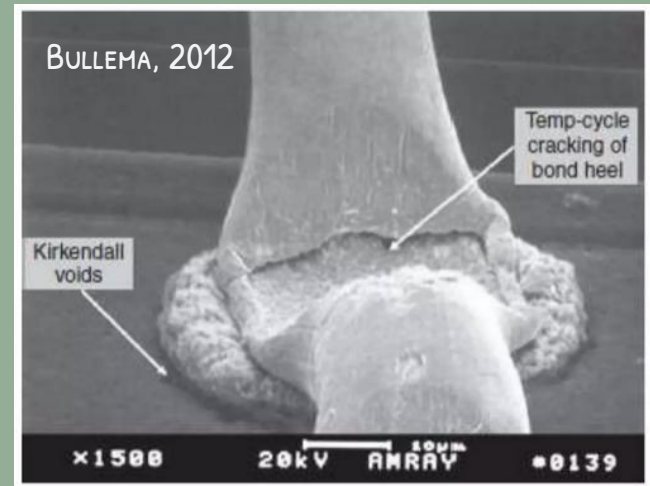
TEMPERING

FORM THE LOOP

SAME AGAIN

TEAR OFF

- BOND UNDERGOES STRESS RELAXATION THROUGH TEMPERING.
- RESIDUAL MECHANICAL STRAIN GRADUALLY DISSIPATES INTERNALLY.
- HEAT ENHANCES MICROSTRUCTURAL STABILIZATION POST-BONDING.
- DIFFUSION BALANCES INTERFACIAL COMPOSITION MORE UNIFORMLY.
- BOND ACHIEVES GREATER TOUGHNESS AND RELIABILITY.
- TEMPERING FINALIZES METALLURGICAL STABILITY AND STRENGTH.





INITIAL CONTACT

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INTERMETALLIC COMPOUND

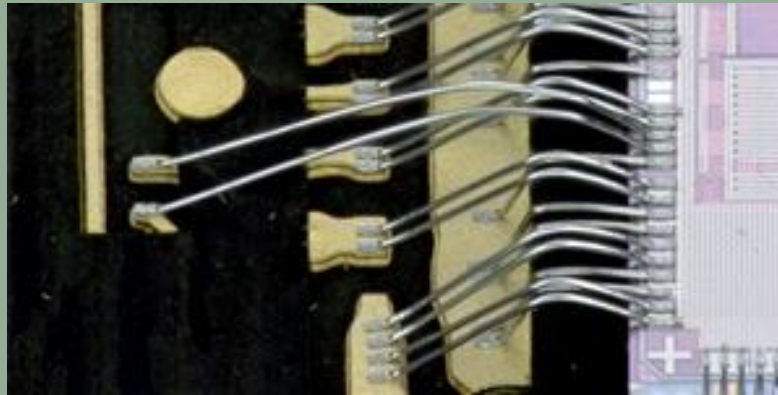
TEMPERING

FORM THE LOOP

SAME AGAIN

TEAR OFF

- CAPILLARY ASCENDS, WIRE FOLLOWS GUIDED TRAJECTORY.
- LOOP HEIGHT DETERMINED BY PROGRAMMED MACHINE PARAMETERS.
- ULTRASONIC VIBRATIONS CEASE DURING UPWARD FORMATION.
- WIRE BENDS SMOOTHLY, DEFINING ELECTRICAL INTERCONNECT.
- MECHANICAL PATH OPTIMIZES STRESS DISTRIBUTION EFFECTIVELY.
- LOOP GEOMETRY ENSURES FUNCTIONAL ELECTRICAL CONNECTION.





INITIAL CONTACT

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TEMPERING

FORM THE LOOP

SAME AGAIN

TEAR OFF

- BONDING TOOL REPOSITIONS FOR SUBSEQUENT CONNECTION.
- WIRE ALIGNS WITH SECOND SUBSTRATE PAD.
- CAPILLARY DESCENDS, INITIATING ANOTHER CONTACT SEQUENCE.
- ULTRASONICS AND FORCE REPLICATE BONDING CYCLE.
- SECOND METALLURGICAL JUNCTION FORMS IDENTICALLY STABLE.
- PROCESS REPEATS ENSURING RELIABLE ELECTRICAL CHAIN.





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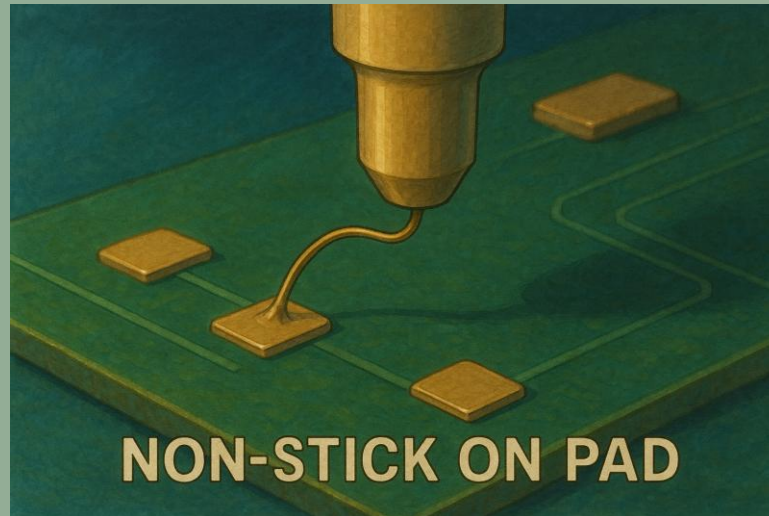
- CAPILLARY CLAMPS WIRE SECURELY NEAR END.
- UPWARD MOTION APPLIES TENSILE FRACTURE FORCE.
- WIRE SEVERS AT PREDETERMINED WEAK POINT.
- TAIL REMAINS POSITIONED FOR SUBSEQUENT CYCLE.
- CLEAN BREAK SUPPORTS CONTINUOUS PRODUCTION EFFICIENCY.
- TEAR-OFF COMPLETES WIRE BONDING OPERATION.



ERRORS

1. Non-Stick on Pad (NSOP)

- WIRE FAILS TO BOND TO PAD
- CAUSES: CONTAMINATION, LOW FORCE, LOW ULTRASONICS
- EFFECT: OPEN CIRCUIT, NO ELECTRICAL CONTACT



ERRORS

1. Non-STICK ON PAD (NSOP)

- WIRE FAILS TO BOND TO PAD
- CAUSES: CONTAMINATION, LOW FORCE, LOW ULTRASONICS
- EFFECT: OPEN CIRCUIT, NO ELECTRICAL CONTACT

2. BOND LIFT

- BOND FORMS BUT LATER DETACHES
- CAUSES: SHORT BOND TIME, POOR SCRUBBING
- EFFECT: INTERMITTENT OR UNRELIABLE CONNECTION



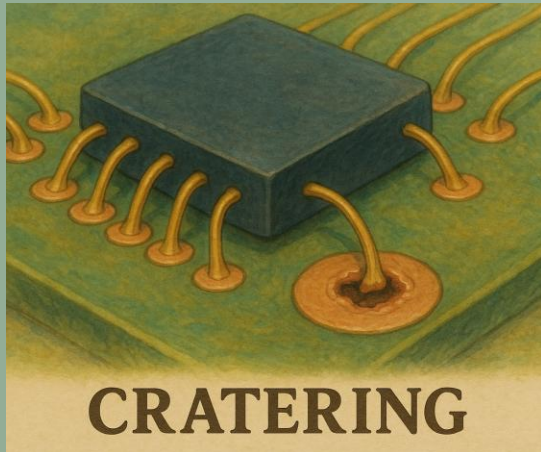
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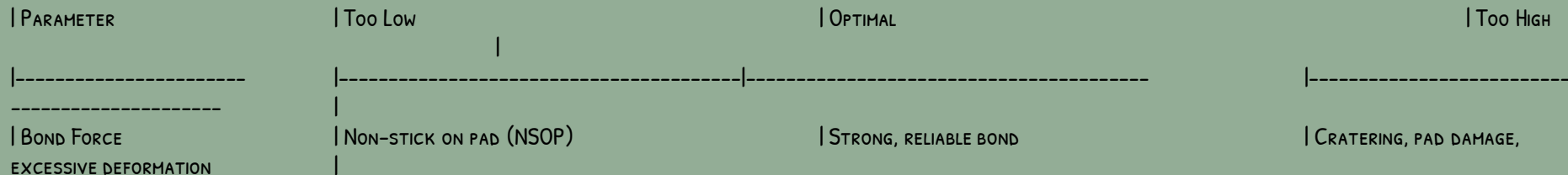
3. CRATERING / PAD DAMAGE

- PAD METALLIZATION OR SILICON DAMAGED
- CAUSES: EXCESSIVE FORCE, POWER, OR TIME
- EFFECT: DEVICE DAMAGE, REDUCED YIELD, LATENT FAILURE



PARAMETERS: BOND FORCE

- APPLIED FORCE PRESSES WIRE AGAINST PAD.
- CORRECT LEVEL ENSURES INTIMATE SURFACE CONTACT.
- TOO LITTLE CAUSES INCOMPLETE MECHANICAL DEFORMATION.
- TOO MUCH RISKS PAD STRUCTURAL DAMAGE.
- FORCE CONTROL CRITICAL FOR CONSISTENT BOND RELIABILITY.





PARAMETERS: ULTRASONIC POWER

- ULTRASONIC VIBRATION SUPPLIES LOCALIZED SCRUBBING ENERGY.
- AMPLITUDE DETERMINES OXIDE DISRUPTION AND INTERDIFFUSION RATE.
- TOO LOW LEADS TO WEAK ADHESION.
- EXCESSIVE POWER DAMAGES WIRE OR SUBSTRATE.
- POWER TUNING DEPENDS ON METALLIZATION AND MATERIAL.

PARAMETER	Too Low	OPTIMAL	Too High
----- -----	----- 	----- 	-----
BOND FORCE	NON-STICK ON PAD (NSOP)	STRONG, RELIABLE BOND	CRATERING, PAD DAMAGE,
EXCESSIVE DEFORMATION			
ULTRASONIC POWER	WEAK BOND, POOR SCRUBBING, NSOP	PROPER OXIDE REMOVAL, STABLE BOND	WIRE NECKING, PAD DAMAGE,
CRATERING			

PARAMETERS: BOND TIME

- DURATION DEFINES EXPOSURE TO ENERGY INPUT.
- SHORT TIME PRODUCES INSUFFICIENT ATOMIC BONDING.
- EXTENDED TIME RISKS BRITTLE INTERMETALLIC FORMATION.
- CAREFUL CONTROL ENSURES OPTIMAL JOINT MICROSTRUCTURE.
- TIME INTERACTS CLOSELY WITH FORCE AND POWER.
- PRECISE TIMING SECURES REPEATABLE BONDING QUALITY.

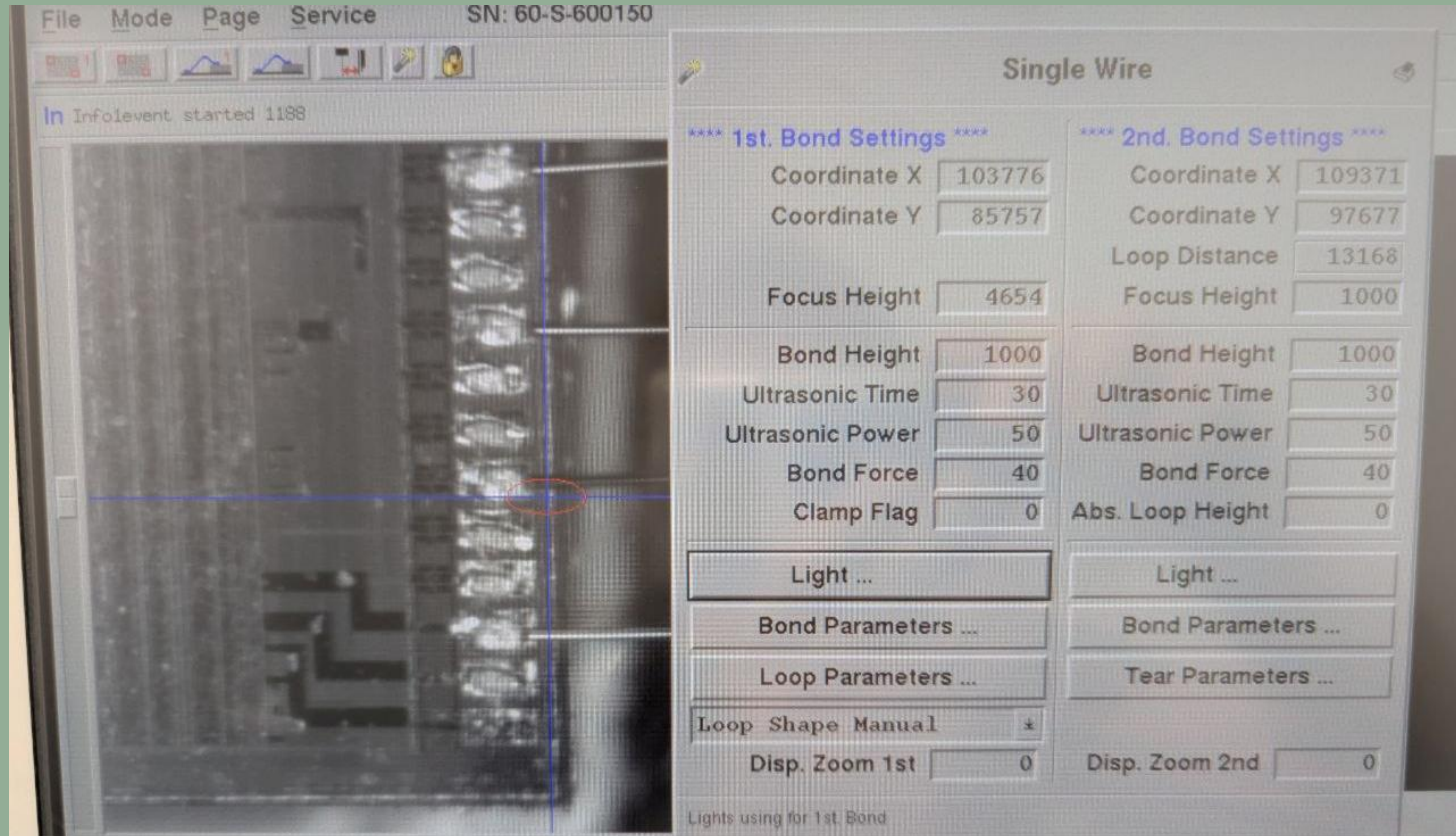
PARAMETER	Too Low	OPTIMAL	Too High
BOND FORCE	NON-STICK ON PAD (NSOP)	STRONG, RELIABLE BOND	CRATERING, PAD DAMAGE,
EXCESSIVE DEFORMATION			
ULTRASONIC POWER	WEAK BOND, POOR SCRUBBING, NSOP	PROPER OXIDE REMOVAL, STABLE BOND	WIRE NECKING, PAD DAMAGE,
CRATERING			

PARAMETERS: SURFACE CLEANLINESS

- SURFACE OXIDES AND CONTAMINANTS HINDER BONDING.
- SCRUBBING EXPOSES FRESH REACTIVE METAL LAYERS.
- CLEAN PADS MAXIMIZE ULTRASONIC EFFICIENCY SIGNIFICANTLY.
- CONTAMINATION LEADS TO UNRELIABLE WEAK CONNECTIONS.
- WIRE AND PAD PREPARATION IS CRITICAL.
- SURFACE INTEGRITY DICTATES FINAL BOND PERFORMANCE.

PARAMETER	Too Low	OPTIMAL	Too High
----- -----	----- 	----- 	-----
BOND FORCE	NON-STICK ON PAD (NSOP)	STRONG, RELIABLE BOND	CRATERING, PAD DAMAGE,
EXCESSIVE DEFORMATION			
ULTRASONIC POWER	WEAK BOND, POOR SCRUBBING, NSOP	PROPER OXIDE REMOVAL, STABLE BOND	WIRE NECKING, PAD DAMAGE,
CRATERING			

THE BOND PLACEMENT



THE BOND PARAMETERS

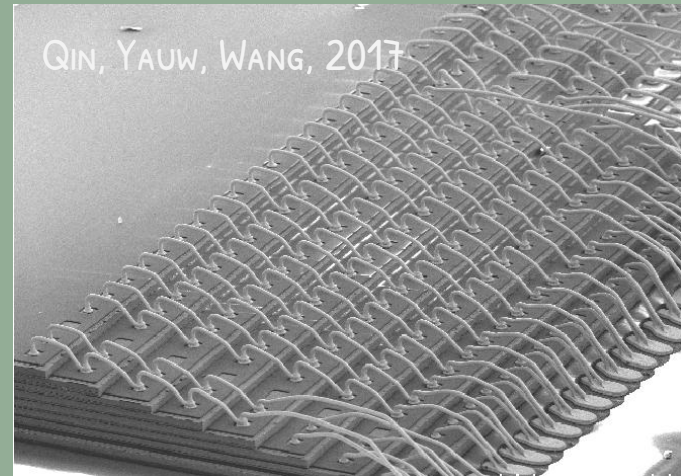
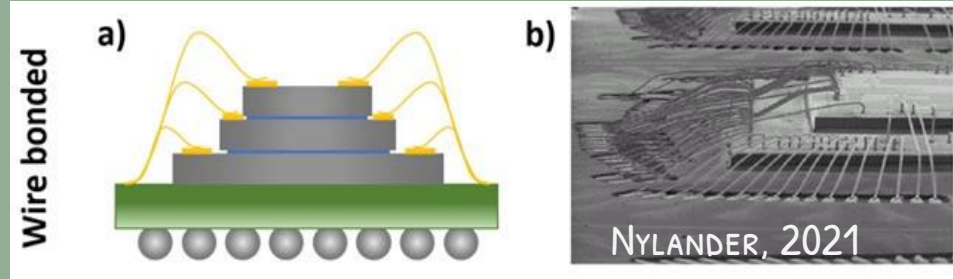
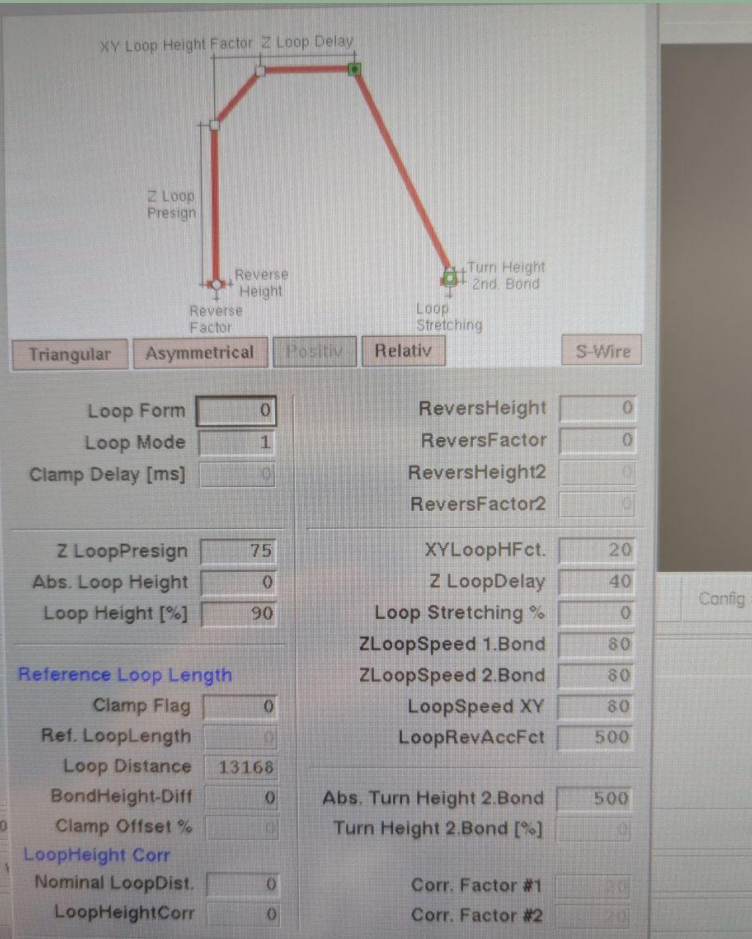
Parameters 1st. Bond

BondDelay	100	Start-BondForce	50	Pgm. Deform. [μm]	6.0
		Start-Time	0	Max. Deform. Diff. [μm]	9.0
		End-BondForce	40	Min. Deform. Diff. [μm]	3.0
		Ramp-Time	0		
TD Flag	1	☐ BForceRampEnable		BPC Deform.Slope	85
TD Force	15			Min. BondTime	10
TD Ramp	200			BPC TemperTime	4
TD Threshold	25	BPC Clamp Threshold	0		
TD Overdrive	200				
TD Steps	0				
☐ S-Shape-Loop		WireCtrlMode	0	USPower Max. Diff.	5
Bond Angle	0	US-Tuned-Ctrl	0	USPower Min. Diff.	0
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		US-RampTime1 [ms]	0	US-RampTime2 [ms]	0

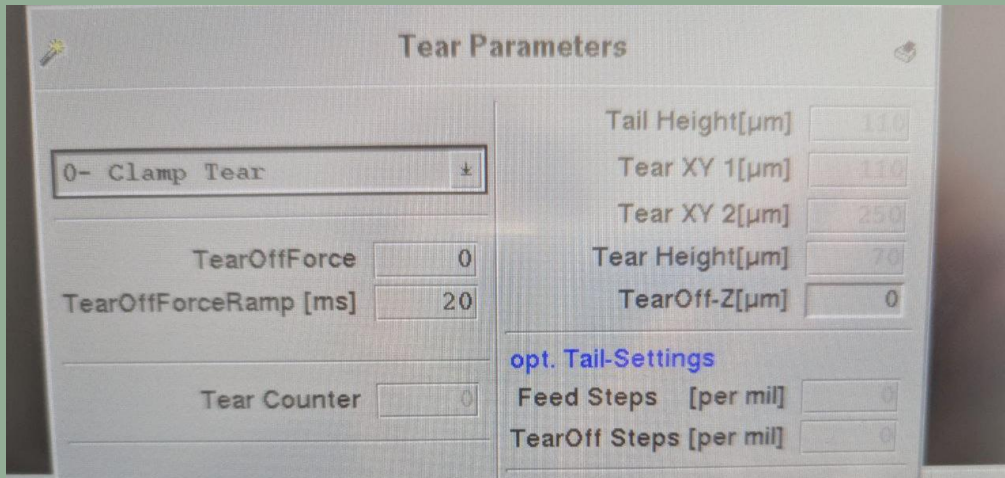
Process Monitoring ...

THE LOOP PARAMETERS

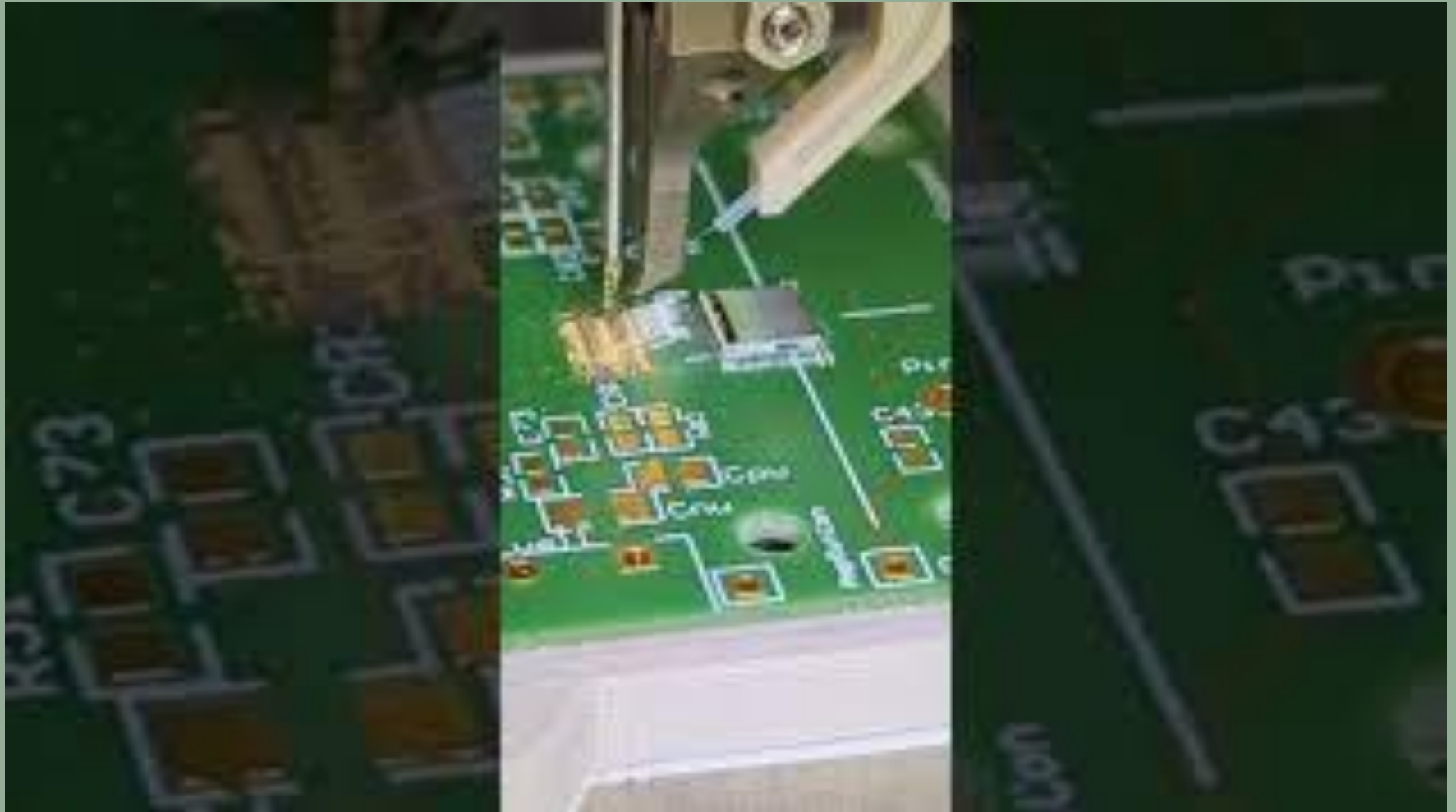
ADJUST THE TRAJECTORY THE
BOND HEAD SHOULD PERFORM
BETWEEN FIRST AND SECOND BOND

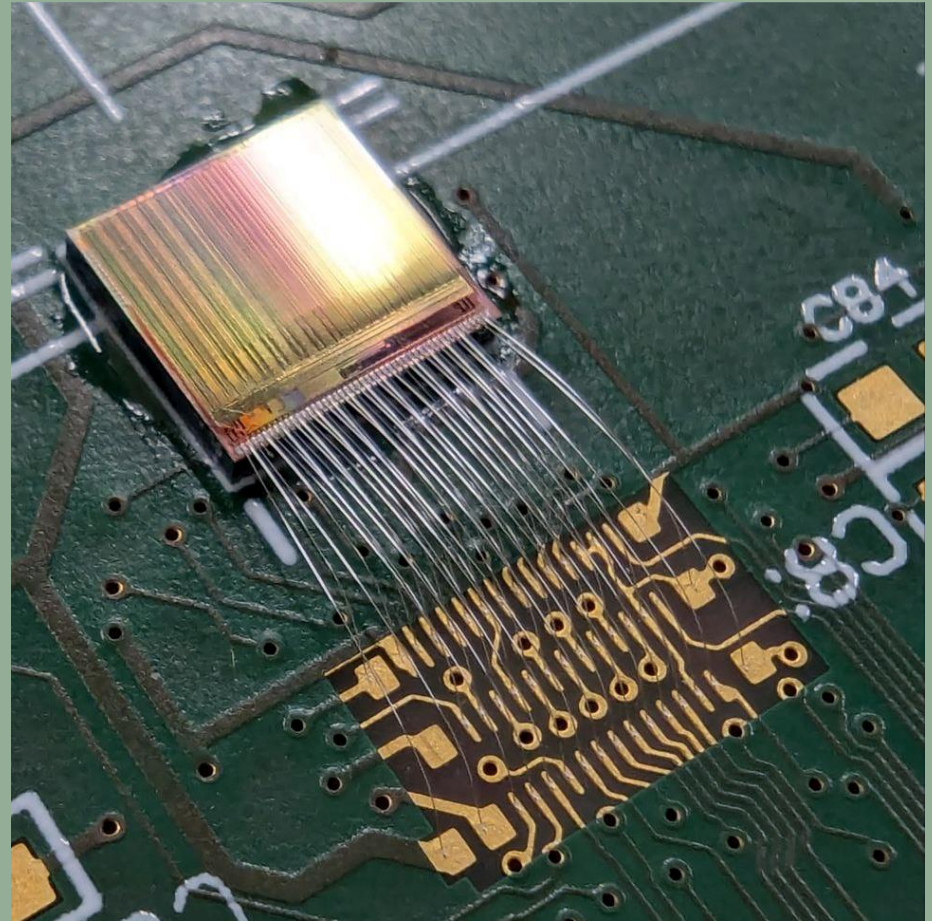
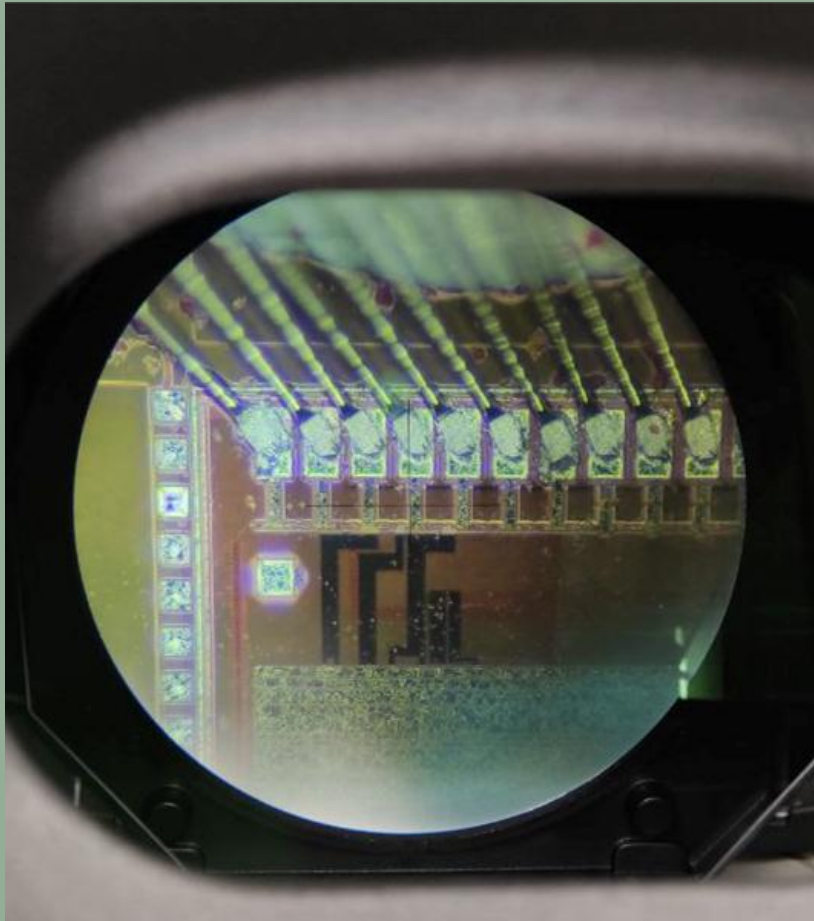


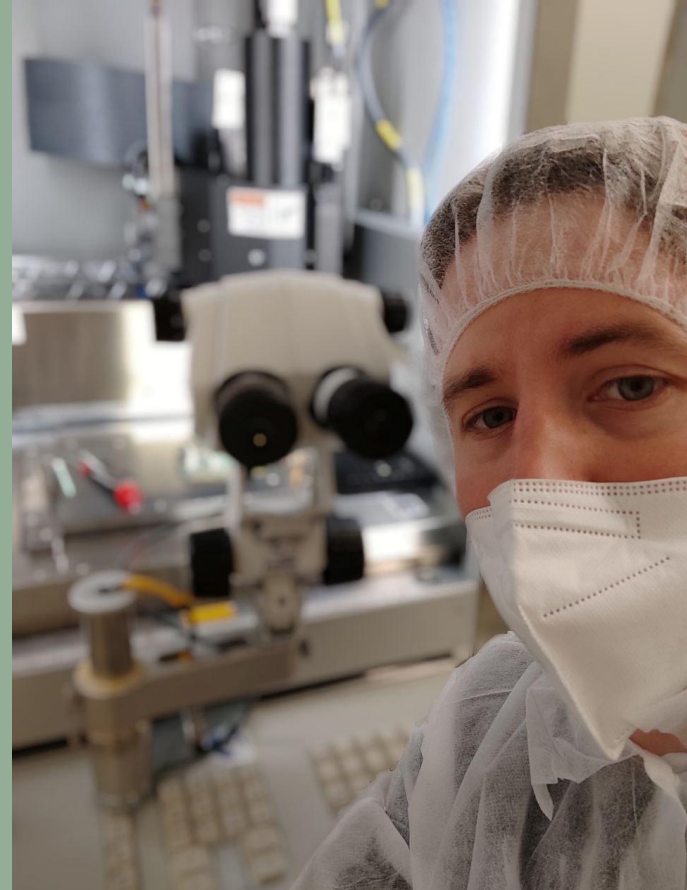
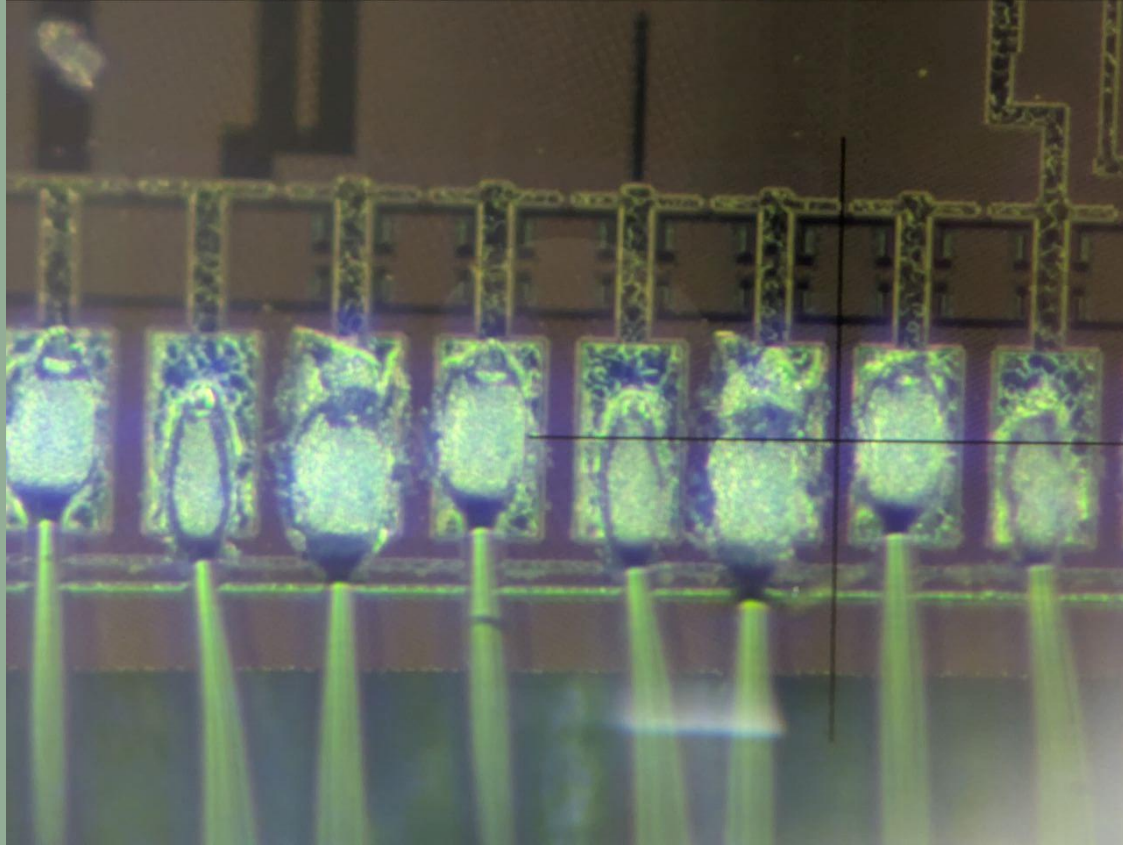
THE TEAR PARAMETERS



CONFIGURE HOW THE WIRE SHOULD BE TORN OFF
AFTER THE SECOND BOND







My RÉSUMÉ

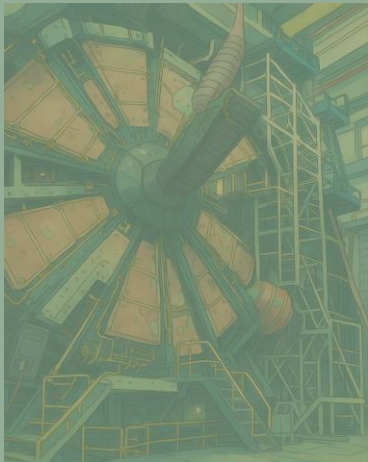
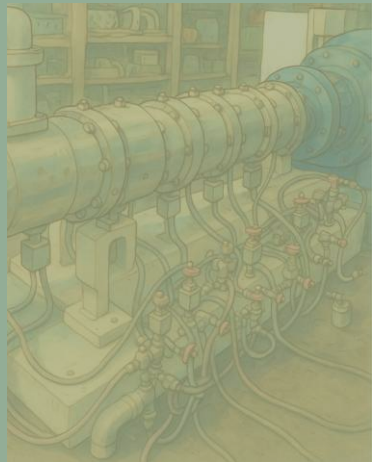
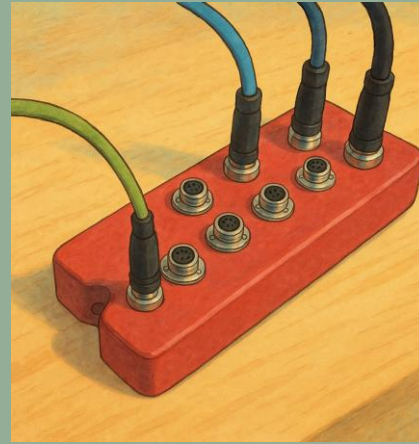
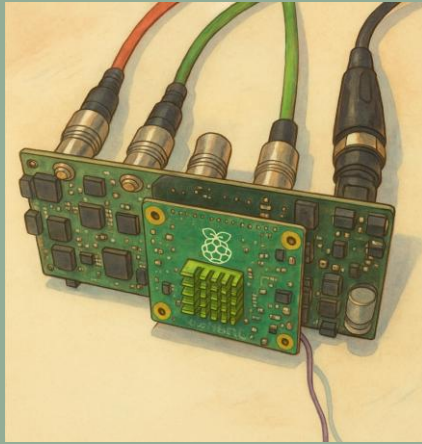
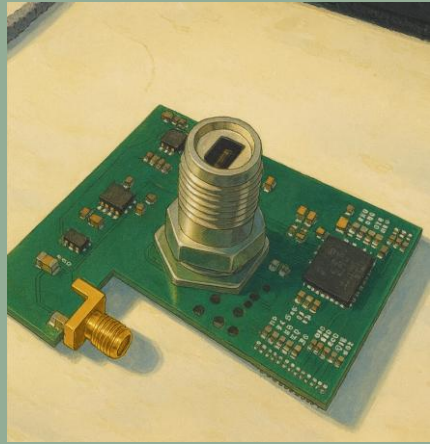
- HARDWARE IS HARD
- 1960 - THIS WAS DONE BY HAND
- IT BECAME BIG-INDUSTRY TECH
- 2030 - 3D-PRINTER LIKE?
- HOW DOES THIS RELATE TO OPEN SOURCE PCB AND CHIP DESIGN?
- WHAT DOES THAT MEAN IN THE FUTURE?

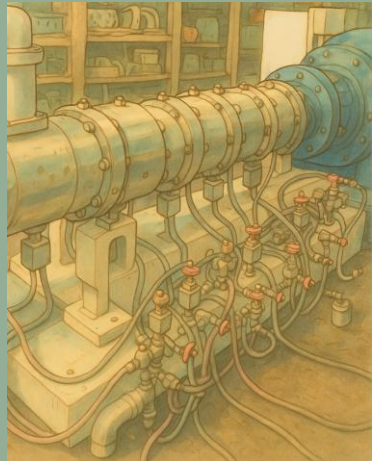
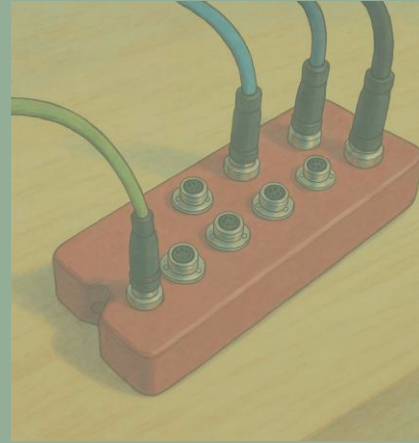
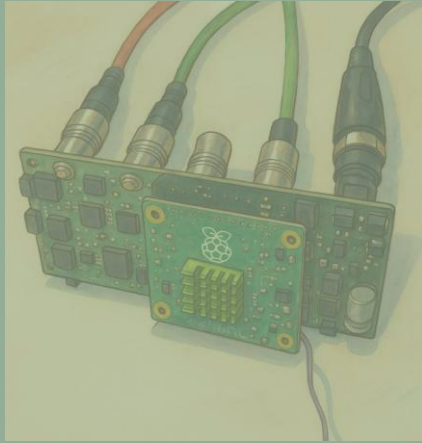
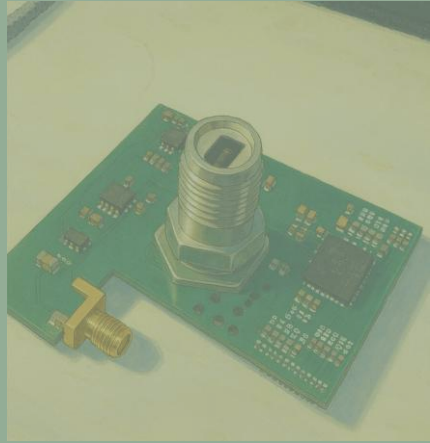
OpenTapeout Conference 06.-07.November 2021

In the last few years Application-Specific-Integrated-Circuits (ASICs) have become one of the most interesting fields to work in for Physicists, Computer-Scientists, Electrical- and Nano-Engineers. It was only a question of time before toolchains for the design of ASICs were democratized.

This event is for anyone interested in learning and sharing how to design ASICs with open source tools.









\$ WHOAMI

> STEPHAN+KICON@BOEKELMANN.NET

#SHAMELESSSELFADVERTISING

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- TEACHING AT TECHNICAL UNIVERSITY OF BOCHUM
- ONBOARDING NEW ENGINEERS AS A CONSULTANT
- DEVELOP MONITORING-SYSTEMS TO BUILD A SAFER FUTURE TOGETHER WITH TABEA, ODIN AND A BUNCH OF OTHERS

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